

(12) **EUROPEAN PATENT APPLICATION**

(21) Application number: 83304617.0

(51) Int. Cl.⁴: **B 41 J 3/20**
H 01 L 49/02

(22) Date of filing: 10.08.83

(30) Priority: 24.11.82 US 444412

(43) Date of publication of application:
25.07.84 Bulletin 84/30

(88) Date of deferred publication of search report: 18.12.85

(84) Designated Contracting States:
DE FR GB

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(54) **Inversely processed resistance heater.**

(57) A unique inverse processed film resistance heater structure is disclosed. A conventional passivation wear layer (110) is deposited directly on a first substrate (120), followed by the deposition and patterning of resistance (140) and conductive (150) layers, and covered by an isolation layer (180) and a thick support layer (190). The thick support layer is then bonded to a second substrate (310) and the first substrate (120) is removed so that a uniform, flat passivation layer is exposed. The result is a film resistor which has a reduced failure rate as compared to the prior art because it is covered by a passivation wear layer with fewer pin-holes and reduced stress.

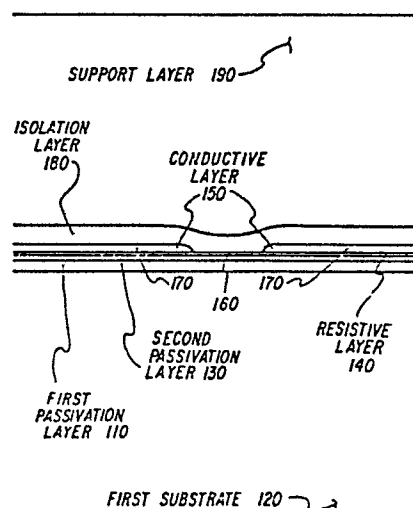


FIG. 2



DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl. 3)
Y	EP-A-0 015 100 (ERIC H. ENGLAND) * Claim 1 *	1	B 41 J 3/20 H 01 L 49/02
Y	US-A-4 169 032 (J.B. HAASE et al.) * Abstract; figure 1 *	1	
A	PATENTS ABSTRACTS OF JAPAN, vol. 3, no. 107 (E-136), 8th September 1979, page 146 E 136; & JP - A - 54 85 734 (MATSUSHITA DENKI SANGYO K.K.) 07-07-1979 * Abstract *	1,13	
			TECHNICAL FIELDS SEARCHED (Int. Cl. 3)
			H 01 L B 41 J
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 29-08-1985	Examiner PELSERS L.
CATEGORY OF CITED DOCUMENTS X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document			

